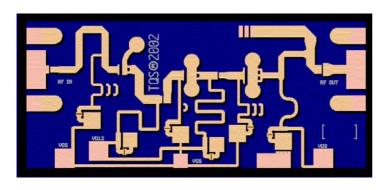


Ka Band Low Noise Amplifier

TGA4507-EPU



Key Features

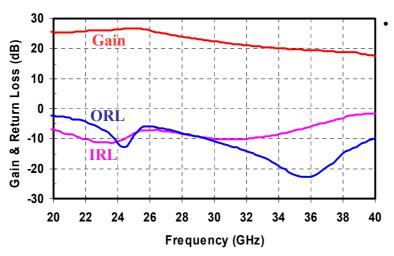
- Typical Frequency Range: 28 36 GHz
- 2.3 dB Nominal Noise Figure
- 22 dB Nominal Gain
- 12 dBm Nominal P1dB
- Bias 3.0 V, 60 mA
- 0.15 um 3MI pHEMT Technology
- Chip Dimensions 1.86 x 0.85 x 0.1 mm (0.073 x 0.033 x 0.004 in)

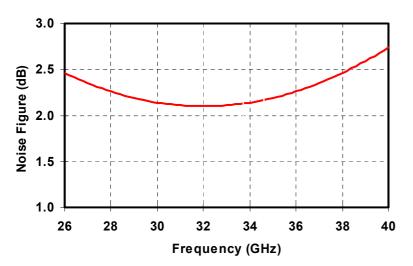
Primary Applications

- Point-to-Point Radio
- Point-to-MultiPoint Radio
 - Ka Band VSAT

Preliminary Measured Data

Bias Conditions: Vd = 3.0 V, Id = 60 mA







TGA4507-EPU

TABLE I MAXIMUM RATINGS 1/

SYMBOL	PARAMETER	VALUE	NOTES
Vd	Drain Voltage	5 V	<u>2/</u>
Vg	Gate Voltage Range	-1 TO +0.5 V	
ld	Drain Current	280 mA	<u>2</u> / <u>3</u> /
Ig	Gate Current	6 mA	<u>3</u> /
P _{IN}	Input Continuous Wave Power	TBD	
P_{D}	Power Dissipation	TBD	<u>2</u> / <u>4</u> /
T _{CH}	Operating Channel Temperature	150 ⁰ C	<u>5</u> / <u>6</u> /
T_M	Mounting Temperature (30 Seconds)	320 °C	
T _{STG}	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P_D.
- 3/ Total current for the entire MMIC.
- 4/ When operated at this bias condition with a base plate temperature of TBD, the median life is reduced from TBD to TBD hrs.
- 5/ Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 6/ These ratings apply to each individual FET.



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TABLE II DC PROBE TESTS (Ta = 25 $^{\circ}$ C, Nominal)

SYMBOL	PARAMETER	MIN.	TYP.	MAX.	UNITS
V_{BVGD3}	Breakdown Voltage Gate-Source			-5	V
V _{P1,2,3}	Pinch-off Voltage		-0.4		V

Q1 is 100 um FET, Q2 is 200 um FET, Q3 is 300 um FET.

TABLE III ELECTRICAL CHARACTERISTICS

(Ta = 25 °C Nominal)

PARAMETER	TYPICAL	UNITS
Drain Voltage, Vd	3.0	V
Drain Current, Id	60	mA
Gate Voltage, Vg	-0.5 to 0	V
Small Signal Gain, S21	22	dB
Input Return Loss, S11	8	dB
Output Return Loss, S22	8	dB
Noise Figure, NF	2.3	dB
Output Power @ 1 dB Compression Gain, P1dB	12	dBm



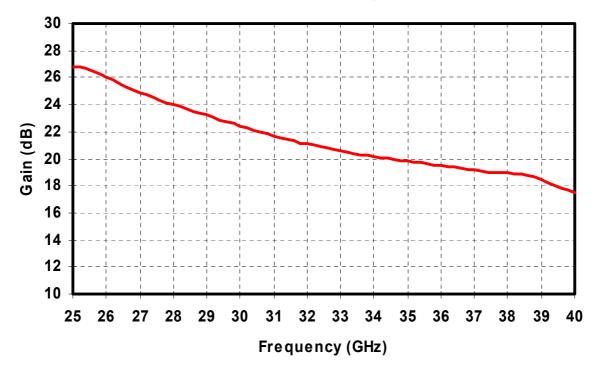
Advance Product Information

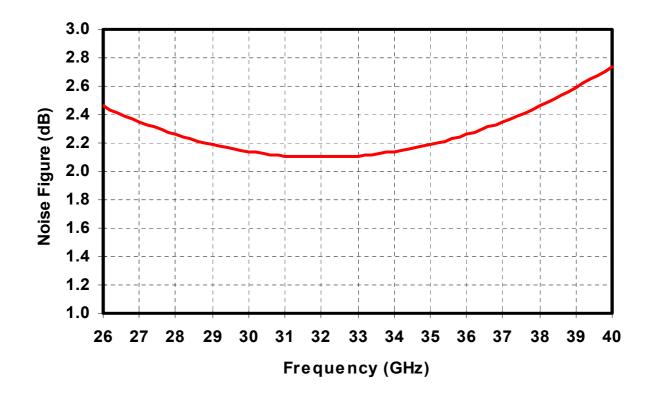
January 7, 2004

TGA4507-EPU

Preliminary Measured Data

Bias Conditions: Vd = 3.0 V, Id = 60 mA



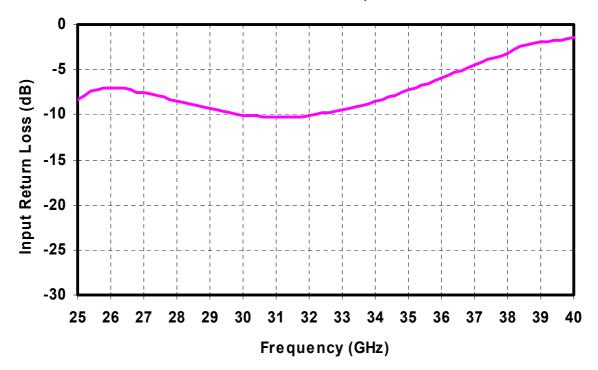


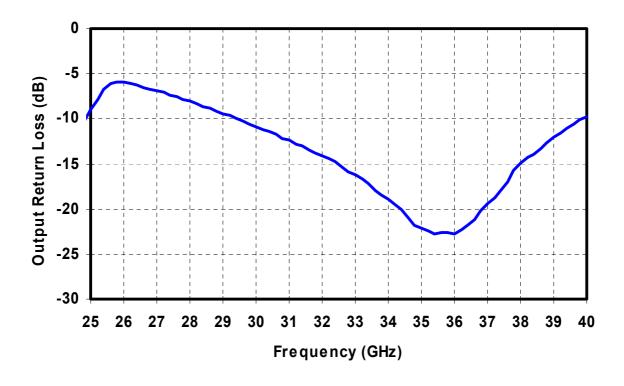


TGA4507-EPU

Preliminary Measured Data

Bias Conditions: Vd = 3.0 V, Id = 60 mA







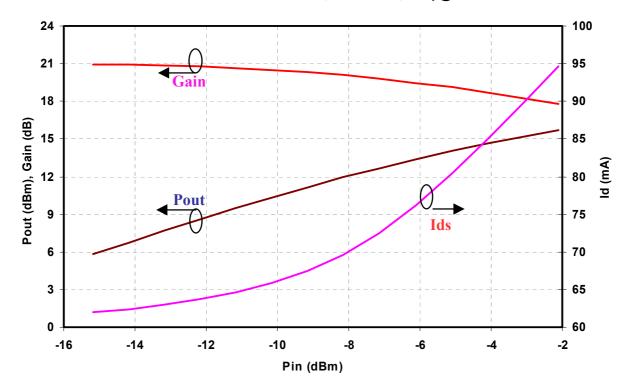
Advance Product Information

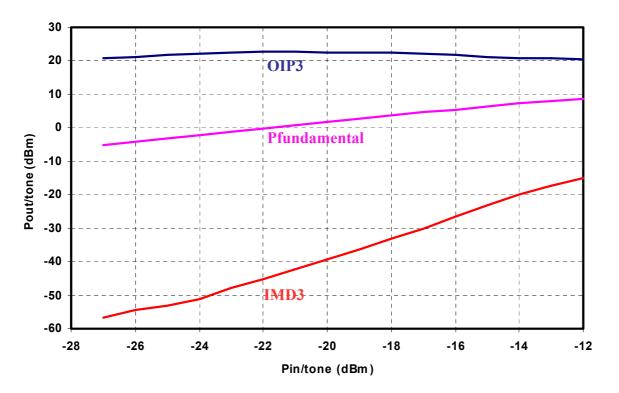
January 7, 2004

TGA4507-EPU

Preliminary Measured Data

Bias Conditions: Vd = 3.0 V, Id = 60 mA, Freq @ 30 GHz

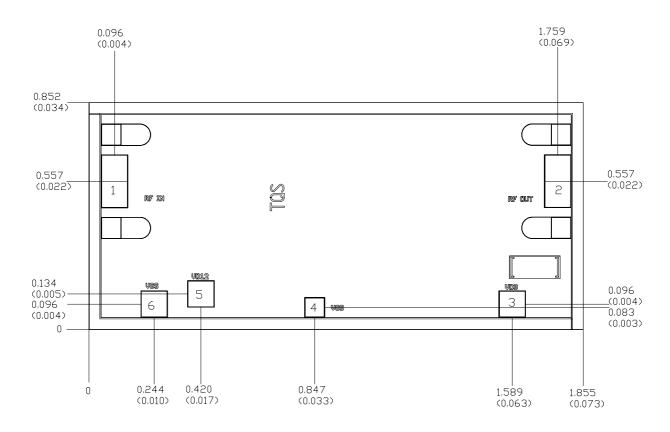






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Mechanical Drawing



Units: millimeters (inches) Thickness: 0.100 (0.004) Chip edge to bond pad dimensions are shown to center of bond pad Chip size tolerance: +/- 0.051 (0.002) Unip size tolerance: +/- 0.051 (0.002) GND is back side of MMIC. Bond pad #1 (RF In) 0.100×0.200 (0.004×0.008) 0.100 × 0.200 0.100 × 0.100 Bond pad #2 (RF Dut) (0.004×0.008) Bond pad #3 (Vd3) (0.004× 0.004) Bond pad #4 (Vg) Bond pad #5 (Vd1,2) $0.075 \times 0.075 (0.003 \times 0.003)$ 0.100 × 0.100 0.100 × 0.100 (0.004× 0.004)

Bond pad #6 (Vg)

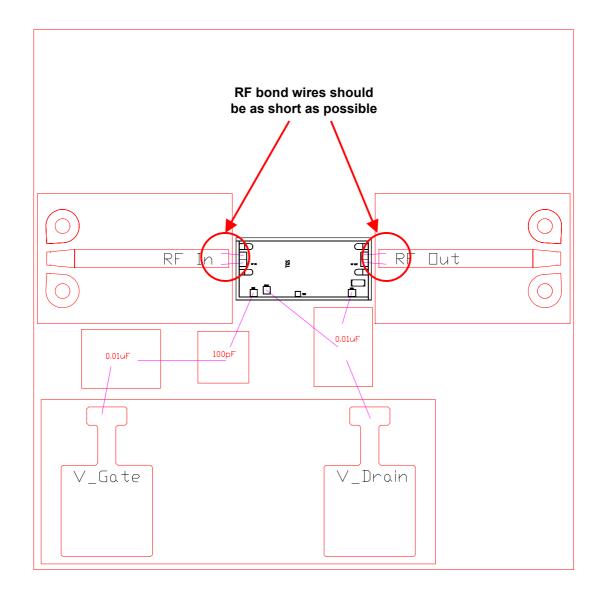
GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

 (0.004×0.004)



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Chip Assembly Diagram



GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.



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Assembly Process Notes

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300 C (30 seconds max).
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 200

 C.

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.